

Supplement

Rhenium(III)-based ternary oxides: Novel materials from straightforward synthesis *via* ALD comprising uncommon reaction pathways

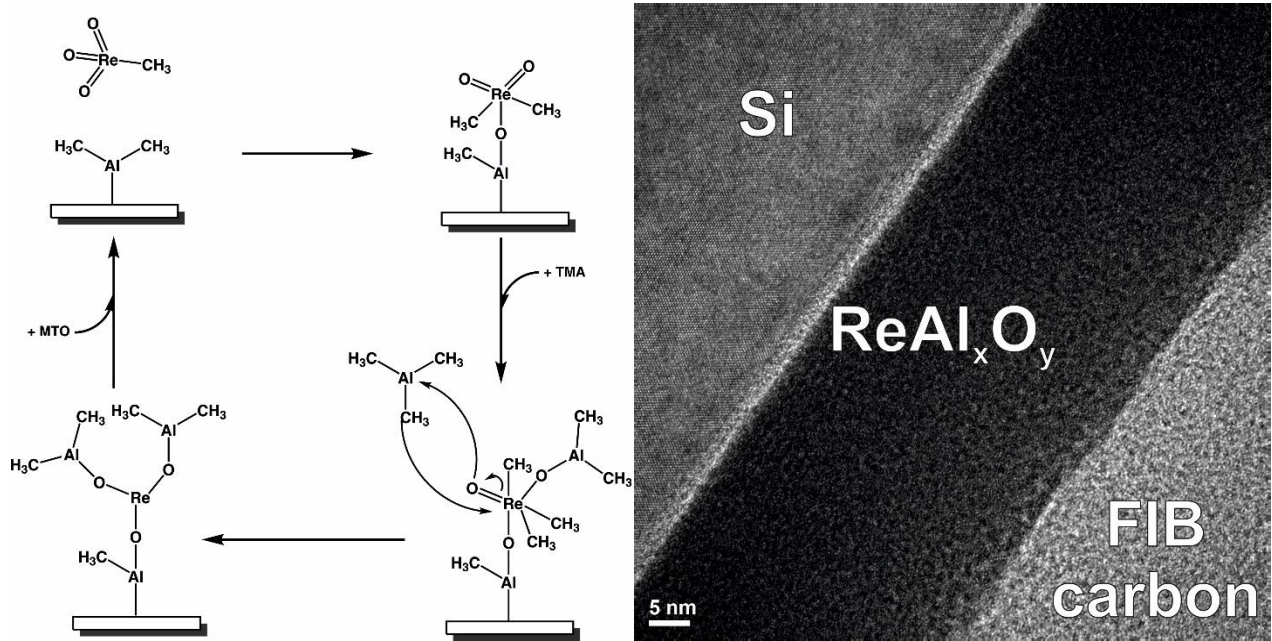


Figure 1: Left: Schematic of the new MTO-TMA ALD process to grow ReAl_xO_y ; Right: TEM image of the ternary ReAl_xO_y thin film on Si.